

**IN THE UNITED STATES PATENT AND TRADEMARK OFFICE**

In re Application of: Ji Zhu et al.

Ser. No.: 10/599,106

Filing Date: September 19, 2006

Attorney Docket No.: IB-1997

For: METHODS FOR FABRICATION OF  
POSITIONAL AND COMPOSITIONALLY  
CONTROLLED NANOSTRUCTURES ON  
SUBSTRATE

Examiner: Allan W. Olsen

Group Art Unit: 1716

Confirmation No.: 4207

**RESPONSE TO RESTRICTION REQUIREMENT**

Mail Stop Amendment  
Commissioner for Patents  
P.O. Box 1450  
Alexandria, VA 22313-1450

Dear Sir:

This is in response to the Restriction Requirement mailed September 14, 2010 for which the time to respond is due on or before the due date of October 14, 2010. Accordingly, this response is timely filed.

**REMARKS**

**Restriction Requirement**

The Examiner is requiring restriction under 35 U.S.C. § 121 and 372 to one of the following inventions:

- I. Claims 1-33, drawn to a method of fabricating a nanostructured array;
- II. Claims 34-66, drawn to a method of fabricating a nanostructured array;
- III. Claims 67-99, drawn to a method of fabricating a nanostructured array;
- IV. Claims 100-117, drawn to a sensor device; and,
- V. Claims 118-135, drawn to a nanostructure array.